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(12) **United States Design Patent**
von Hollen et al.

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(54) **FACE MASK**

(75) Inventors: **Dirk Ernest von Hollen**, Clark, NJ (US); **Eric Andrew Lieberman**, Scotch Plains, NJ (US); **William E. Parr**, Ledgewood, NJ (US); **Donald Fraser van Royen**, New York, NY (US)

(73) Assignee: **Koninklijke Philips Electronics N.V.**, Eindhoven (NL)

(**) Term: **14 Years**

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(51) **LOC (9) Cl.** **28-02**

(52) **U.S. Cl.** **D24/110.4; D24/110.1; D24/110.5**

(58) **Field of Classification Search** D24/107, D24/108, 110, 110.1, 110.4, 110.5; 128/201.21, 128/201.23-201.26

See application file for complete search history.

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Primary Examiner — Ian Simmons

Assistant Examiner — Eleni H Aldridge

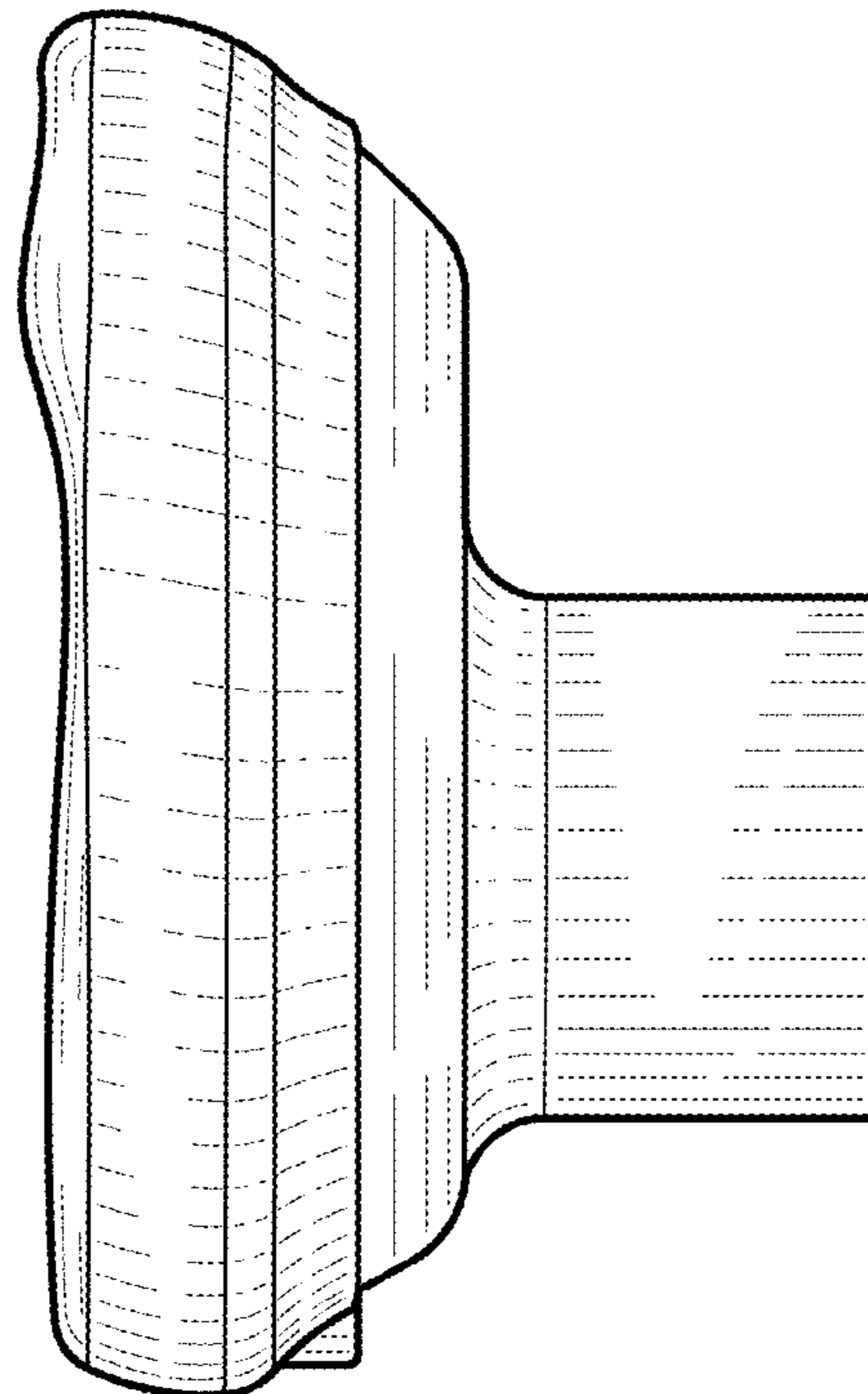
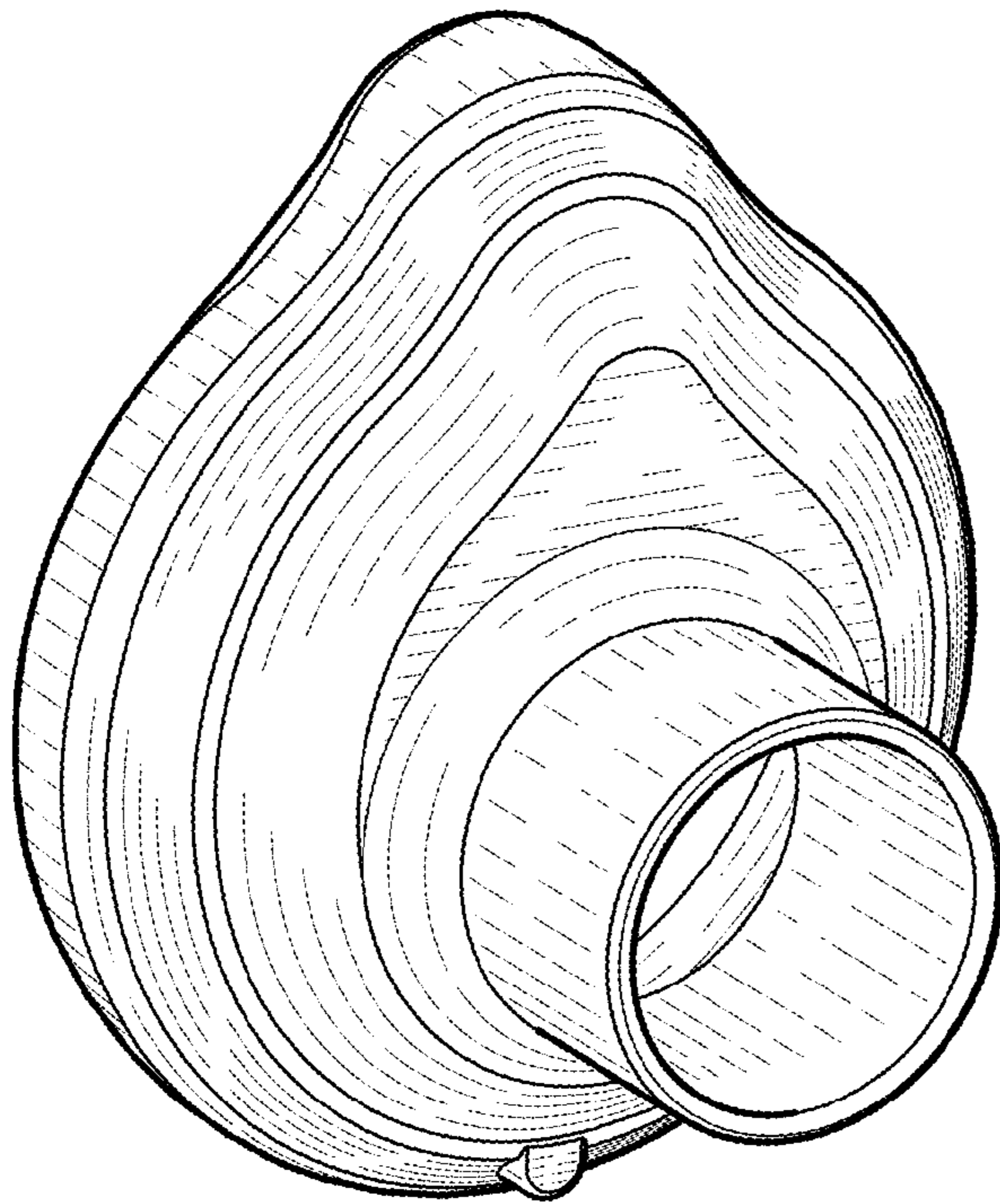
(57) **CLAIM**

The ornamental design for a face mask, as shown.

DESCRIPTION

FIG. 1 is a perspective view showing my design;
FIG. 2 is a front elevational view thereof;
FIG. 3 is a rear elevational view thereof;
FIG. 4 is a right side elevational view thereof;
FIG. 5 is a left side elevational view thereof;
FIG. 6 is a top plan view thereof; and,
FIG. 7 is a bottom plan view thereof.

1 Claim, 4 Drawing Sheets



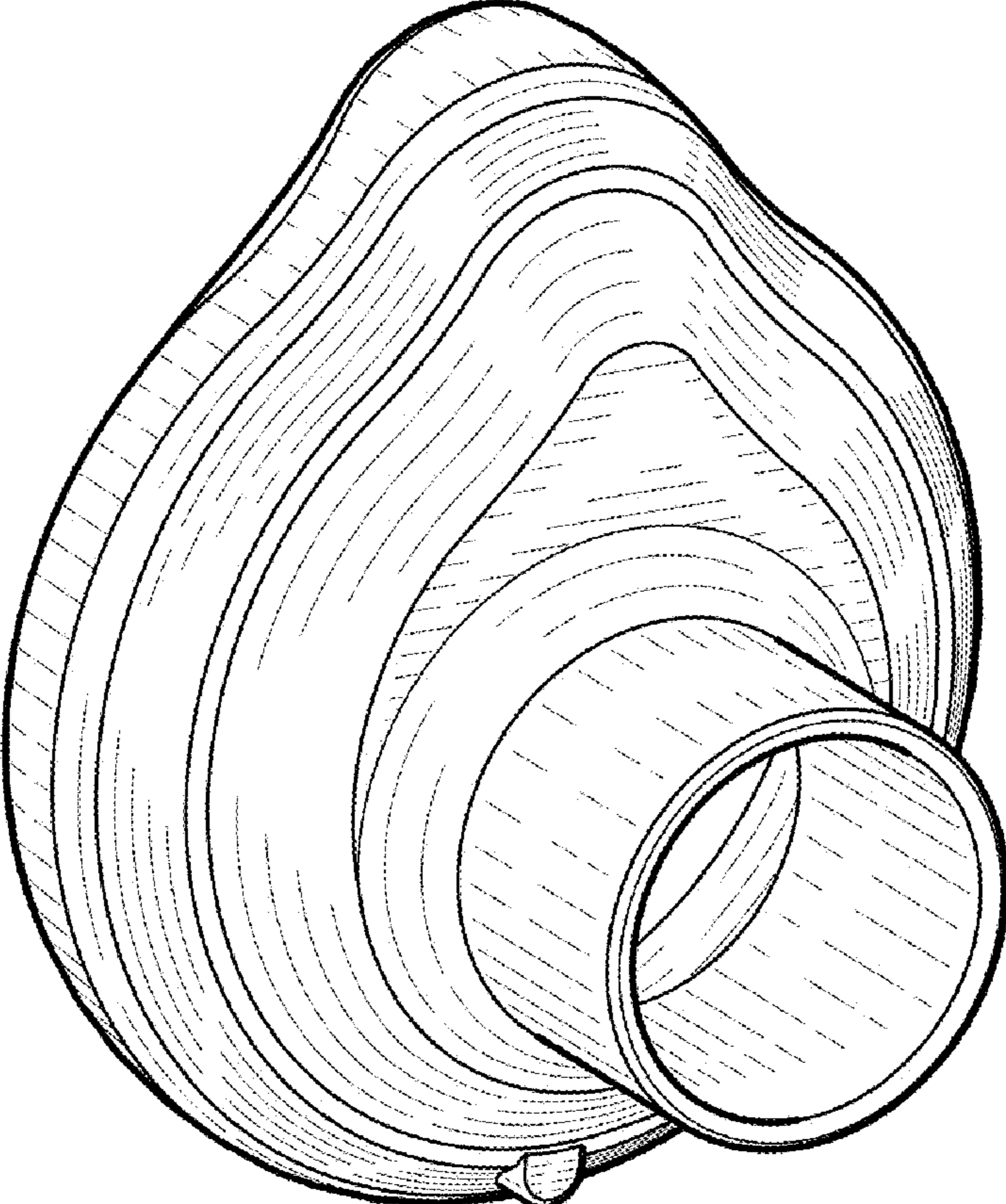


FIG. 1

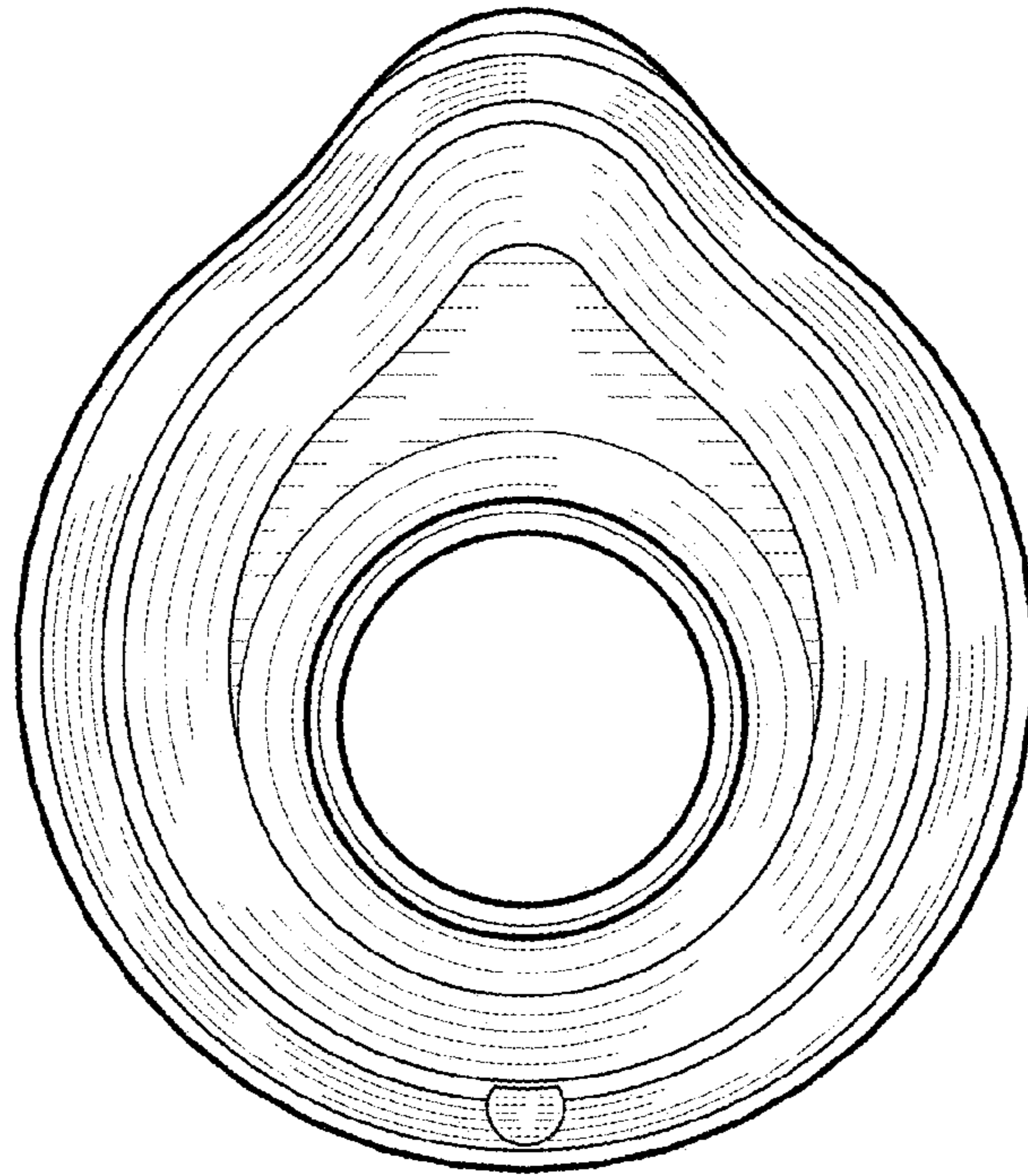


FIG. 2

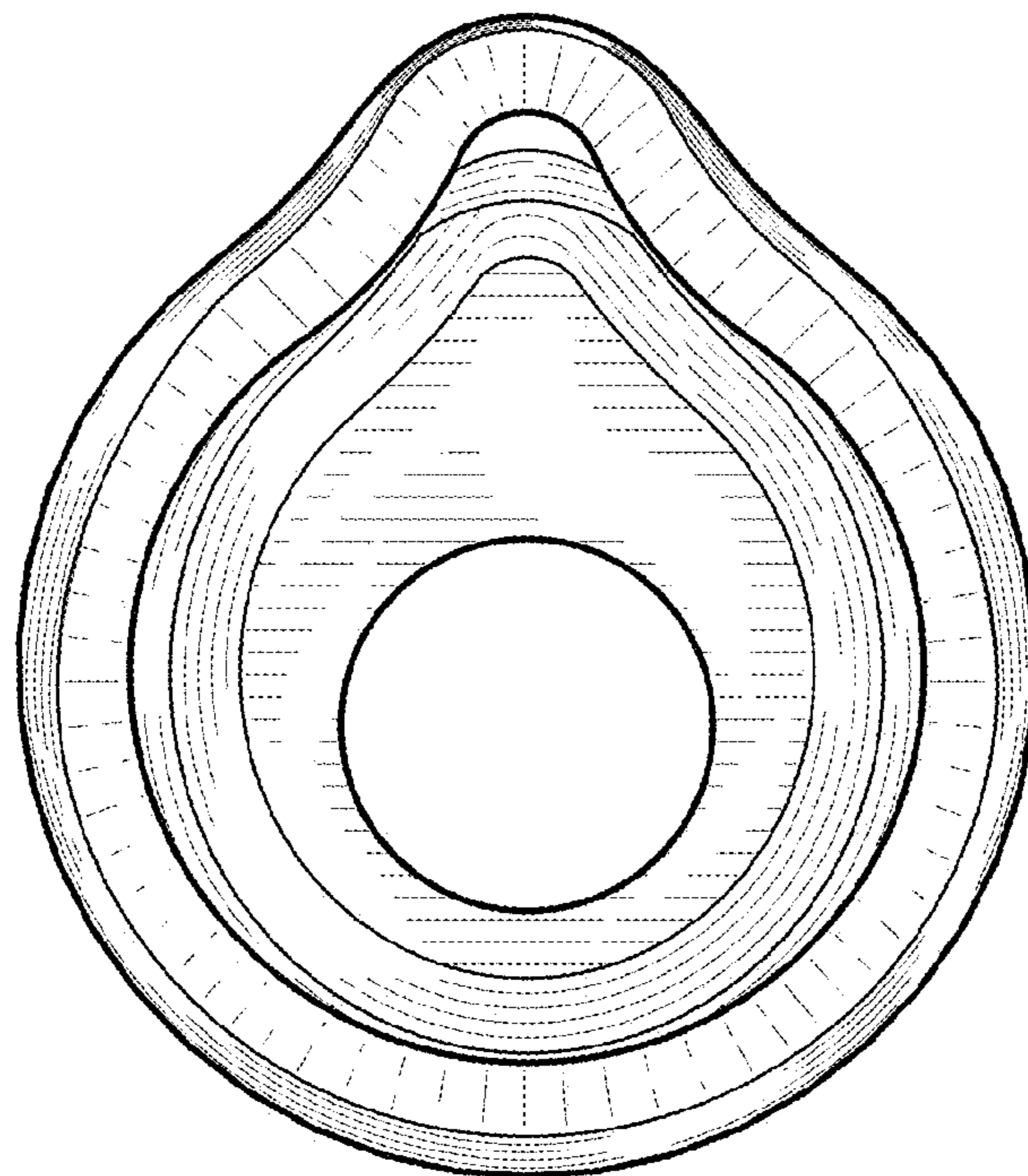


FIG. 3

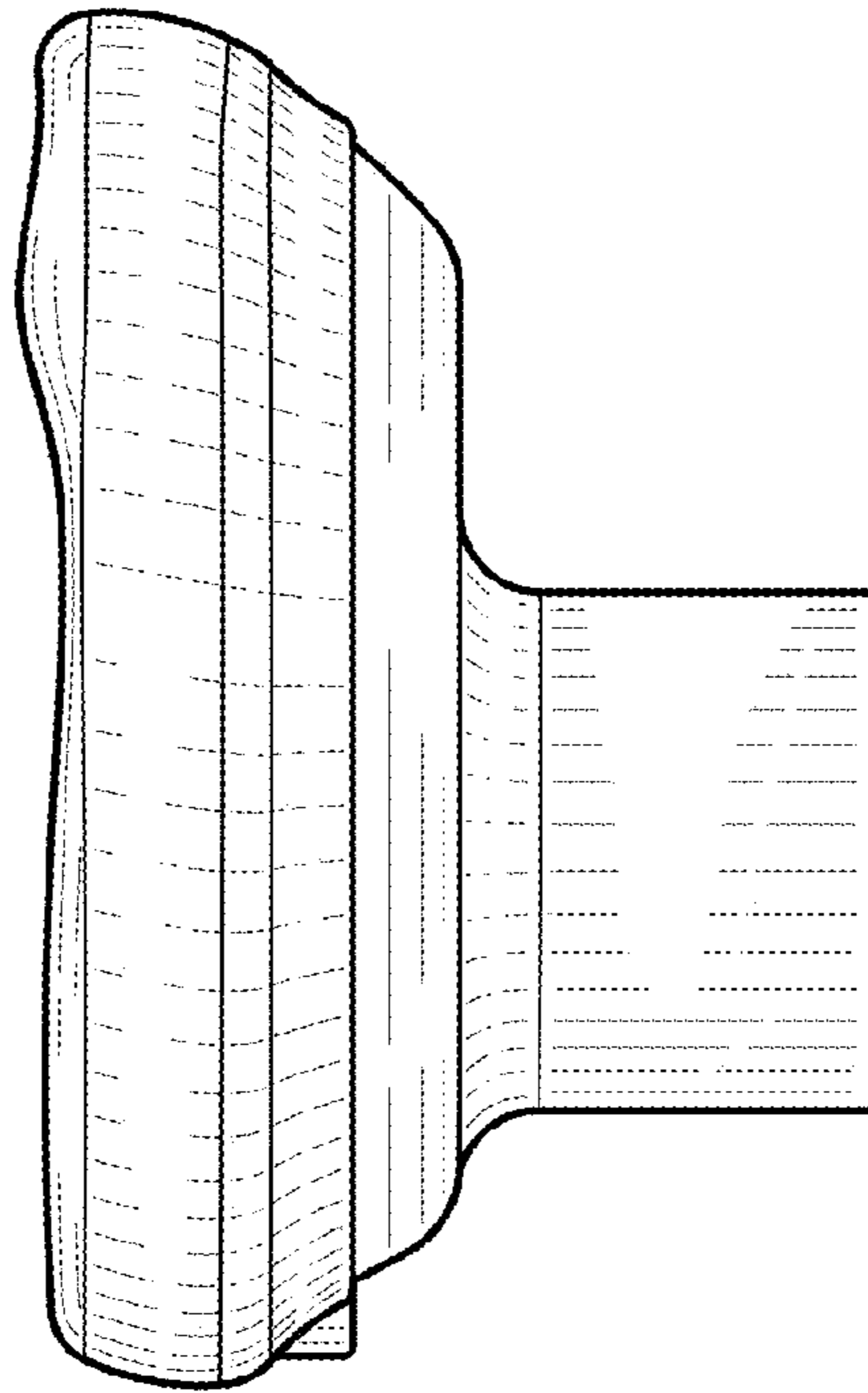


FIG. 4

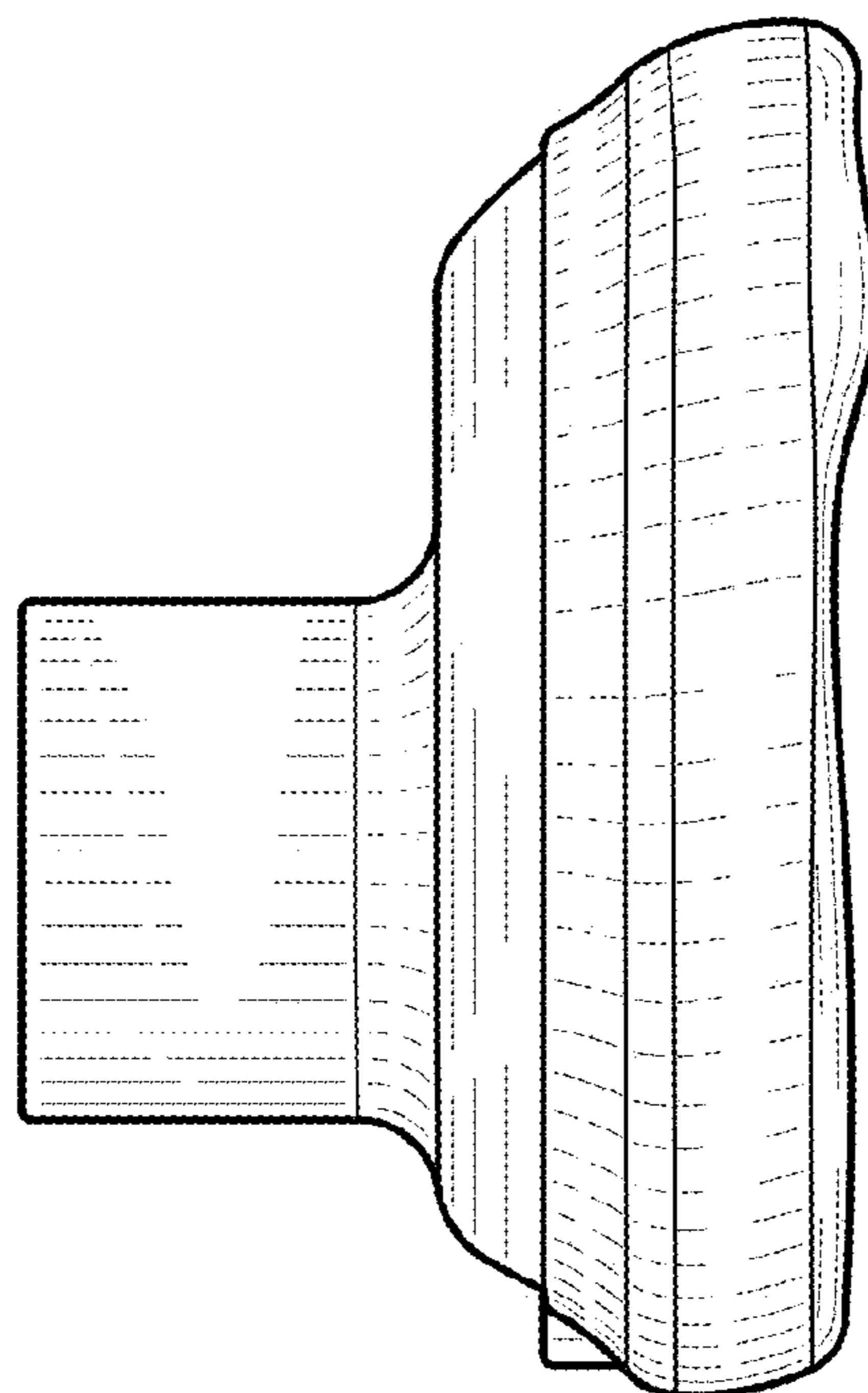


FIG. 5

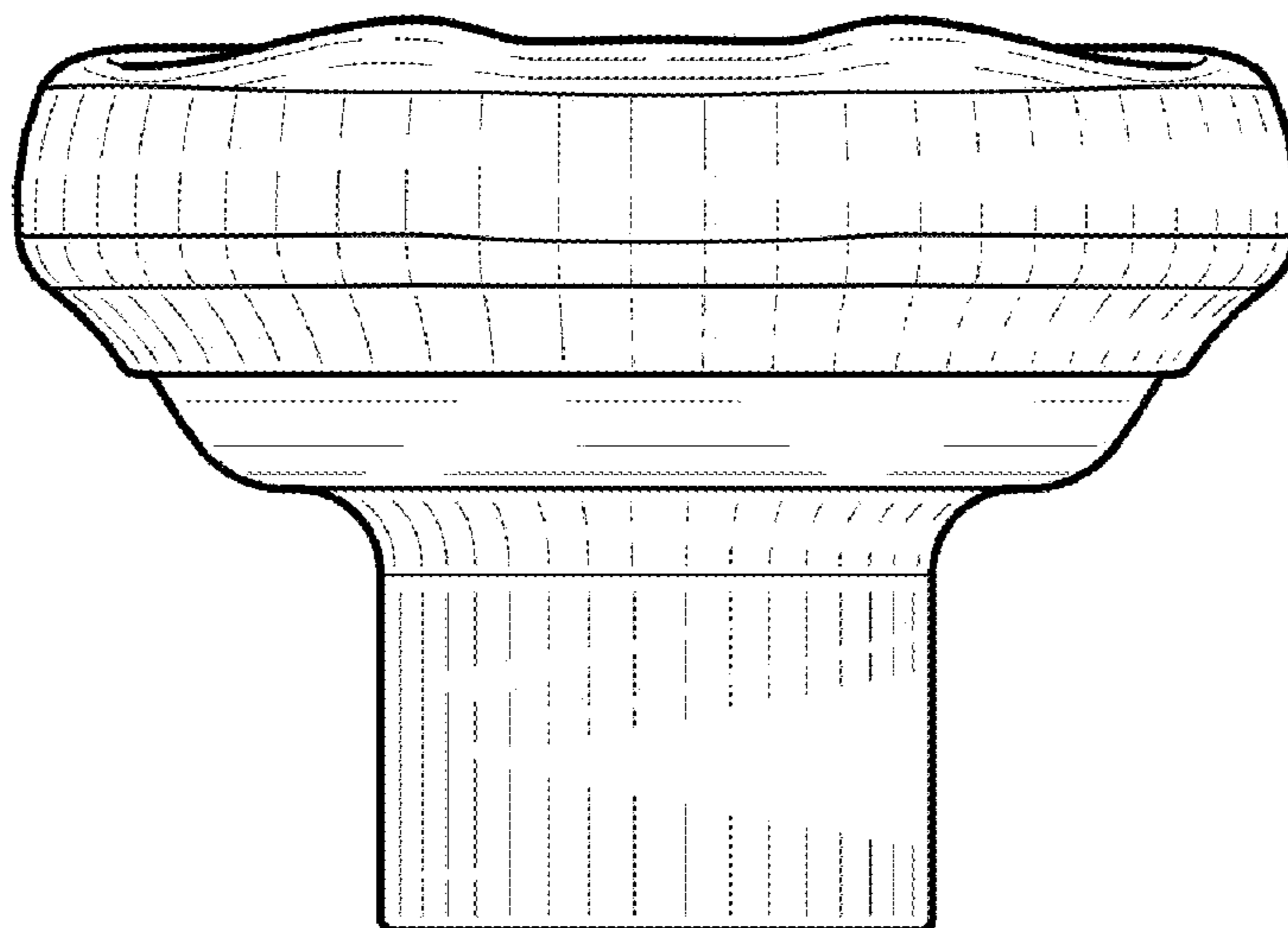


FIG. 6

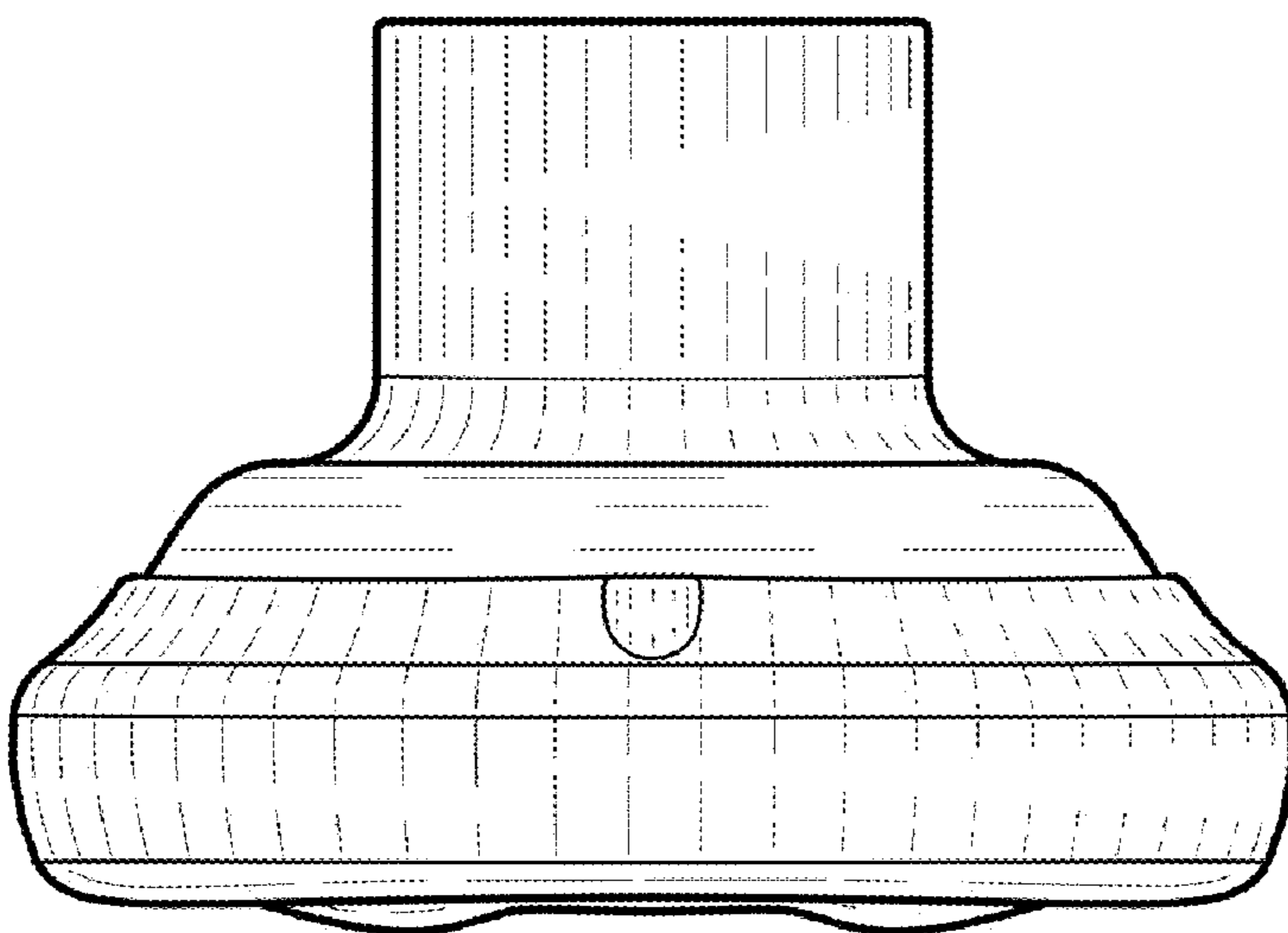


FIG. 7